

Corrigendum

Corrigendum #2 to “Expanding Thermal Plasma Chemical Vapour Deposition of ZnO:Al Layers for CIGS Solar Cells”

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In the article titled “Expanding Thermal Plasma Chemical Vapour Deposition of ZnO:Al Layers for CIGS Solar Cells” [1], there was an error in the references list, as reference number 4 cited a wrong author’s name (M. Jean) instead of Jonas Lähnemann, who is the actual author of that article [2].

References

- [1] K. Sharma, B. L. Williams, A. Mittal et al., “Expanding thermal plasma chemical vapour deposition of ZnO:Al layers for CIGS solar cells,” *International Journal of Photoenergy*, vol. 2014, Article ID 253140, 9 pages, 2014.
- [2] J. Lähnemann, *Spectrally resolved current losses in Cu (In,Ga)Se₂ thin-film solar cells*, Freie Universität Berlin, Berlin, Germany, 2008.